

Pfeiffer Exhibits Vacuum and Abatement Solutions at SEMICON Taiwan

Pfeiffer Vacuum+Fab Solutions, a member of the Busch Group, announce its presence at SEMICON Taiwan 2025.

ASSLAR, GERMANY, July 31, 2025 /EINPresswire.com/ -- The booth of Pfeiffer Vacuum+Fab Solutions will showcase the brand's wide range of vacuum solutions and technological expertise for the semiconductor industry. This includes vacuum pumps, contamination management systems, leak detectors, valves, gas abatement solutions and comprehensive sub-fab management, all aimed at improving



UltiDry multi-stage dry vacuum pump from Pfeiffer Vacuum+Fab Solutions. Source: Pfeiffer Vacuum+Fab Solutions.

the infrastructure of the semiconductor manufacturing facilities in Taiwan.

Range of vacuum and abatement solutions

Among the highlights of the exhibition are several innovative products.

The UltiDry multi-stage dry vacuum pump combines robustness and low energy consumption, even under harsh conditions. It has been engineered to enhance powder management, handle high inlet flows, and withstand corrosive gases.

The high-temperature thermal abatement system on display combines the wide process coverage of flame abatement with the fuel-free aspects of plasma abatement. It features low operating costs and secondary emissions and is capable of destroying the molecular process gas NF3 at class-leading levels with extremely low NOx. This system provides a sustainable solution with a minimal carbon footprint for chemical vapor deposition (CVD) and metal-etch processes.

Trade show visitors can discover these new developments and more from Pfeiffer Vacuum+Fab Solutions at SEMICON Taiwan from September 10-12, 2025 at booth K2870 in TaiNEX Hall 1 and 2, Taipei, Taiwan. The event offers an excellent opportunity for attendees to engage with industry

leaders and learn more about the latest advancements in vacuum and abatement technology.

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